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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/665,366	09/19/2000	Douglas O. Powell	EN9-99-026	5058

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EXAMINER

COMPTON, ERIC B

ART UNIT	PAPER NUMBER
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3726

DATE MAILED: 05/10/2004

11

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application No.

09/665,366

Applicant(s)

POWELL, DOUGLAS O.

Examiner

Eric B. Compton

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– The MAILING DATE of this communication appears on the cover sheet with the correspondence address –
Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on September 16, 2003.
- 2a) ☒ This action is **FINAL**. 2b) ☐ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1-80 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1-80 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on _____ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some * c) ☐ None of:
- ☐ Certified copies of the priority documents have been received.
 - ☐ Certified copies of the priority documents have been received in Application No. _____.
 - ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- 1) ☒ Notice of References Cited (PTO-892)
- 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)
- 3) ☐ Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
Paper No(s)/Mail Date _____
- 4) ☐ Interview Summary (PTO-413)
Paper No(s)/Mail Date. _____
- 5) ☐ Notice of Informal Patent Application (PTO-152)
- 6) ☐ Other: _____

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DETAILED ACTION

Claim Rejections - 35 USC § 112

1. The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

2. Claims 79-80 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the enablement requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to enable one skilled in the art to which it pertains, or with which it is most nearly connected, to make and/or use the invention.

Claims 79-80 require that the conducting metallurgical metal of the claims 1 and 46, respectively, comprises a material selected from: "a conductive paste having metal particles present in a volume fraction above a percolation threshold."

With regards to this limitation, Applicant discloses:

If the metals employed are *non-fusible* at acceptable processing temperatures, such as below 300°C, then they must be present in a volume fraction greater than the percolation threshold, or the point at which particle to particle contact is guaranteed.

Specification, page 27 (emphasis added). The Examiner interprets "non-fusible" to not relate to a metallurgical bond. Thus, the fact that the metal particle volume fraction is above a threshold, only guarantees particle-to-particle contact, not a metallurgical bond.

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Claim Rejections - 35 USC § 103

3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

4. Claims 1-3, 7-10, 12-14, 16-18, 20-21, 37-42, 45-48, 51- 53, 64-68, and 79-80, are rejected under 35 U.S.C. 103(a) as being unpatentable over U.S. Patent 5,744,758 to Takenouchi et al in view of U.S. Patent 6,054,761 to McCormack et al.

Takenouchi et al disclose a multi-layered electronic structure and a method for making said structure (see Figures 7(a)-7(e), 8, & 9), comprising the steps of:

- a. Providing a plurality of sub-composites (12) comprising: providing a layer of dielectric material (14,16) having a top and bottom;
- b. providing a layer of electrically conducting material (13) on one of the top surface of the dielectric layer;
- c. forming at least one passage (18) through the dielectric layer;
- d. depositing electrically conducting material (32, 34) in at least one of the at least one passage through the dielectric layer;
- e. removing portions of the layer of electrically conducting material to define a pattern of circuitry (see Figures 7(d) and 7(e));
- f. stacking a plurality of sub-composites (Figure 9);
- g. aligning the plurality of sub-composites (it is inherent that the structures are aligned);

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h. joining the plurality of sub-composites such that the electrically conducting material in at least one on the at least one the blind vias makes electrically contact by forming a metallurgical bond (see col. 10, lines 65-67) to the conductive pattern (by heat press, col 11, lines 63-65); and

i. filling the spaces between adjacent sub-composites with electrically insulating material (via heat pressing, see Figure 8).

However, Takenouchi et al do not disclose that conductive paste forms a metallurgical bond.

McCormack et al disclose a conductive paste for interconnects "capable of ***forming metallurgical bonds to metal terminals and metal pads*** and do not generate significant amounts of gaseous by-products or non-volatile residue when processed." Col. 2, lines 47-50 (emphasis added). The reference notes that prior art conductive paste had reliability issues due to high thermal cycling. See Col. 2, lines 30-45.

Regarding claims 1, 46, and 68, it would have been obvious to one having ordinary skill in the art at the time the invention was made to have formed the multi-layered electronic structure by the method of Takenouchi et al using a conductive paste capable of forming metallurgical bonds, in light of the teachings of McCormack et al, in order to provide a more reliable bonds resistant to high thermal cycling.

Regarding claims 66 and 67, an electronic package, formed by the method above is shown and described. Furthermore, it is inherent that such structures are used for mounting electrical components.

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Regarding claims 2-3, and 47-48, Takenouchi et al disclose that the dielectric layer (16) may be polyimide (col 6, line 4)

Regarding claim 7, it is inherent in Takenouchi et al that the conducting material may be solderable (col 9, lines 38-40).

Regarding claims 8-9, 14, and 51-52, Takenouchi et al disclose that the conducting material is copper foil (col 10, line 30).

Regarding claims 10 and 12, Takenouchi et al disclose that the conducting material may be electroplated (col 10, line 38).

Regarding claim 13, this step is inherently accomplished in Takenouchi et al.

Regarding claims 16 and 45, Takenouchi et al disclose that the conducting material is patterned with a resist, which is a protective cover.

Regarding claim 17, Takenouchi et al disclose that the passages may be formed by laser (col 10, line 33).

Regarding claim 18, see Figure 7(e) of Takenouchi et al, wherein the conducting material deposited in a passage does not extend beyond the opening of the passage.

Regarding claims 20-21, and 53, Takenouchi et al disclose that the conducting material is a metal deposited in the passages in by plating (col 10, line 5).

Regarding claims 37-41, Takenouchi et al discloses bonding via pressure in a vacuum under inert atmosphere (see col, 10, lines 55-60).

Regarding claims 42, 64, and 65, Takenouchi et al inherently disclose that the structures are filled with a thermoset plastic (16, see col 12, lines 3-5).

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Regarding claims 79-80, McCormack et al disclose that the conductive paste has metal particles, which will inherently fuse when melted. Col. 4, lines 52-54.

5. Claims 4-6, 11, 15, 19, 24-33, 35-36, 49-50, 54- 58, and 60-63 are rejected under 35 U.S.C. 103(a) as being unpatentable over Takenouchi et al/ McCormack et al in view of US Patent 4,915,983 to Lake et al.

Takenouchi et al/ McCormack et al disclose the invention cited above. However, they do not disclose the particulars of the invention as claimed by Applicant.

Lake et al disclose a multi-layered electronic structure and a method for making said structure (see Figure 8) very similar in structure to both Takenouchi et al and Applicant's inventions. Many of the particulars not disclosed by Takenouchi et al are disclosed Lake et al, which are apparently all in the art of forming interconnects.

Regarding claims 4-6, 11, 15, 19, 24-33, 35-36, 49-50, 54- 58, and 60-63, it would have been obvious to one having ordinary skill in the art at the time the invention was made to have formed the sub-composites of Takenouchi et al/ McCormack et al using the various interconnect forming techniques well-known in the art, in light of the teachings of Lake et al, in order to take advantage of well-known interconnect forming technology, thus saving capital costs on retooling production lines for new product runs.

Regarding claims 4 and 49, Official Notice is taken that liquid crystal polymer film is well known in the circuit board arts and a skilled artisan would have found it obvious at time of invention to use such in the method of Takenouchi et al/ McCormack et al.

Regarding claims 5, and 50, Lake et al disclose that the dielectric (50) may be polyimide (col 9, line 33) and/or include a mesh or screen of glass (col 10, lines 37-38).

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Regarding claim 15, Lake et al disclose that the dielectric material is applied to the foil using a press roll (col 9, line 15).

Regarding claim 6, see Figure 8, step 1 of Lake et al.

Regarding claim 11, Official Notice is taken that applying a coating by physical vapor deposition to a substrate comprising vacuum evaporation or sputtering is well known in the art and a skilled artisan would have found it obvious at time of invention to use such in the method of Takenouchi et al.

Regarding claim 19, see Figure 8, step 5, or Lake et al.

Regarding claims 24-26, 28, 29, 30, 31, 33, 54, 55, and 56, Lake et al disclose a layer of tin lead alloy may be applied over the copper foil by a continuous electroplating process (col 9, lines 57-59).

Regarding claims 27 and 57, it would have been obvious to one having ordinary skill in the art at the time the invention was made to have provide a cap having a thickness of 0.0001 to .0004 inch, since it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or workable ranges involves only routine skill in the art. *In re Aller*, 105 USPQ 233.

Regarding claim 32, Takenouchi et al disclose that the circuitry is formed by resist patterning (col 10, lines 48-50).

Regarding claims 35, 60-62, Official Notice is taken that aligning structure such as providing holes in the laminate layers and a jig having corresponding aligning pins and indicia (registration marks) are well known in the art. Applicant, also alludes to the

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fact such structures are known, referring to slots and pins as standard alignment means (page 34, lines 2-3).

Regarding Claims 36 and 63, Lake et al disclose that the layers will be soldered coated (col 9, line 39).

Regarding claim 58, Official Notice is taken that coating a substrate with oxides (e.g. tin oxide) are known in the art to roughen the surface for subsequent bonding and a skilled artisan would have found it obvious at time of invention to apply a coating for such purpose.

6. Claims 22-23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Takenouchi et al/ McCormack et al in view of US Patent 3,601,523 to Arndt.

Takenouchi et al/ McCormack et al disclose the invention cited above. However, they do not disclose that the conducting material provided in the passage is a conducting paste.

Arndt discloses a method for filling a passageway with a conducting paste in order to conductively contact the circuitry from one side of a dielectric to another.

Regarding claim 22, it would have been obvious to one having ordinary skill in the art at the time the invention was made to have used a conducting paste in the passage of Takenouchi et al/ McCormack et al, in light of the teachings of Arndt, in order to provide a more low resistant connection than by plating (see col 1, lines 60+).

Regarding claim 23, Arndt uses a squeegee (20) to apply the conducting paste.

7. Claims 34 and 59 are rejected under 35 U.S.C. 103(a) as being unpatentable over Takenouchi et al/ McCormack et al in view of US Patent 4,921,157 to Dishon et al.

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Takenouchi et al/ McCormack et al disclose the invention cited above. However, they do not disclose treating the dielectric layer and patterned circuitry with fluorine-containing plasma.

Dishon et al/ McCormack et al disclose a method for treating a circuit board with exposed soldering. The surfaces are treated with a fluorine-containing plasma in order to remove oxides and provide a more efficient solder joint.

Regarding claims 34 and 59, it would have been obvious to one having ordinary skill in the art at the time the invention was made to have treated the structure of Takenouchi et al/ McCormack et al with fluorine-containing plasma, in light of the teachings of Dishon et al, in order to remove surface oxides from the solder contacts.

8. Claims 37-44 and 69-78 rejected under 35 U.S.C. 103(a) as being unpatentable over Takenouchi et al/ McCormack et al in view of US Patent 5,635,010 to Pepe et al.

Takenouchi et al/ McCormack et al disclose the invention cited above. The reference relies on pressure and heat to bond the structures. However, it does not specifically disclose providing filling the spacing between adjacent structures with a liquid, which is transformed into a solid.

Pepe et al disclose a method for bonding layers to form a laminate (see Figures 9-12). A dielectric adhesive, preferably a polyimide, applied as a liquid is provide on the to close voids and help bond substrates together. "The preferred polyimide exhibits sufficient viscous flow at the initial temperature and pressure conditions such that it fills all voids between adjacent chips and excess adhesive extrudes from the chip stack to achieve minimal thickness of the adhesive layer" (col 7, lines 58-63).

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Regarding claims 37 and 69, it would have been obvious to one having ordinary skill in the art at the time the invention was made to have provided a liquid insulator to bond the structures of Takenouchi et al/ McCormack et al, in light of the teachings of Pepe et al, in order to fill the voids between the structures.

Regarding claims 37-44, and 76-78, see col 8, lines 49-64 of Pepe et al regarding bonding with pressure in a vacuum with an inert atmosphere.

Regarding claims 70-71, the liquid may include epoxy, an organic resin.

Regarding claims 73-74, Official Notice is taken that inorganic filler and cross-linking is the art to provide structures of added strength and that a skilled artisan would have found it obvious at the time of invention to have provided either for such purpose.

Regarding claim 74, it is inherent that the liquid resin is moved by capillary action.

Regarding claim 75, the liquid resin is placed on the top periphery of the structures.

Response to Arguments

9. Applicant's arguments filed September 16, 2003 ("Response"), have been considered but they are not found fully persuasive.

Applicant argues that Takenouchi et al, does not disclose a conductive paste capable of forming a metallurgical bond. Response, pg. 16. Applicant is correct in that Takenouchi et al, do not explicitly disclose the conductive paste forms a metallurgical bond. Therefore, the 102 rejection based on this reference is withdrawn. While it is not

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clear what type of conductive paste the reference uses, it in no way precludes the use a conductive paste that forms a metallurgical bond.

Based on the amendment, the claims are now rejected as being obvious over Takenouchi et al in view of McCormack et al. Applicant never explicitly discloses the purpose of using a conductive paste capable of forming a metallurgical bond. It can only be assumed that a metallurgical bond is superior to using only an adhesive bond as suggested by Takenouchi et al. In fact, Applicant seems to suggest both types of paste may be used.

If the metals employed are *non-fusible* at acceptable processing temperatures, such as below 300°C, then they must be present in a volume fraction greater than the percolation threshold, or the point at which particle to particle contact is guaranteed. If at least some of the conductive material is a low melting metal or alloy, such as having a melting point on the order of below 300°C, then heat can be used during the curing process of the conductive paste, *causing metallurgical bonding* between conductive paste particles and/or metal surfaces in contact with the paste.

Specification, page 27 (emphasis added). The Examiner interprets “non-fusible” to not relate to a metallurgical bond. Applicant cites and incorporates by reference the teachings of McCormack et al. Specification, page 28. Therefore, it is assumed that Applicant is relying on the conductive paste capable of forming a metallurgical bond for the at least some of the same reasons taught by McCormack et al. That reference notes that prior art conductive paste had reliability issues due to high thermal cycling. See Col. 2, lines 30-45. Therefore, that reference provides a motivation for providing a conductive paste capable of forming the metallurgical bond, in order to provide reliable bonds resistant to high thermal cycling in a multi-layered circuit substrate.

Applicant's remaining arguments are moot in light of this new rejection.

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Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP

§ 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire **THREE MONTHS** from the mailing date of this action. In the event a first reply is filed within **TWO MONTHS** of the mailing date of this final action and the advisory action is not mailed until after the end of the **THREE-MONTH** shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than **SIX MONTHS** from the date of this final action.

Contact Information

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Eric B. Compton whose telephone number is (703) 305-0240. The examiner can normally be reached on M-F, 9-5.

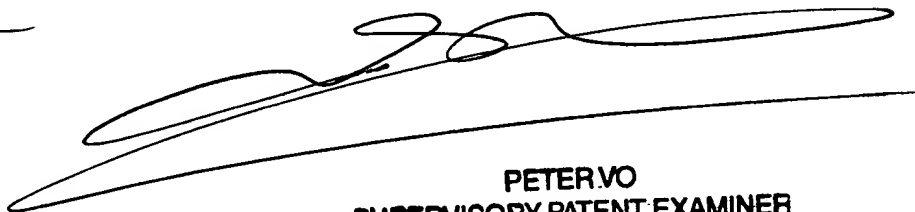
If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Peter B. Vo can be reached on (703) 308-1789. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).



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